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Lionel Presmanes, V Gunasekaran, Yohann Thimont, I Sinnarasa, Antoine Barnabe, et al.. Sub-ppm NO2 sensing in temperature cycled mode with Ga doped ZnO thin films deposited by RF sputtering. 8th GOSPEL Workshop Gas sensors based on semiconducting metal oxides: basic understanding & application fields, Vicenzo Guidi, Jun 2019, Ferrara, Italy. 10.3390/proceedings2019014048 . hal-02192689

HAL Id: hal-02192689 https://laas.hal.science/hal-02192689v1

Submitted on 24 Jul 2019

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Sub-ppm NO₂ sensing in temperature cycled mode with Ga doped ZnO thin films deposited by RF sputtering

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1. Abstract

In this work Ga doped ZnO thin films have been deposited by RF magnetron sputtering onto a silicon micro-hotplate and their structural, microstructural and gas sensing properties have been studied. ZnO:Ga thin film with a thickness of 90 nm has been deposited onto a silicon based micro-hotplates without any photolithography process thanks to a low cost and reliable stencil mask process. Sub-ppm sensing (500 ppb) of NO₂ gas at low temperature (50 °C) has been obtained with promising responses R/R0 up to 18.

2. Results

Micro-hotplates have been prepared using photolithographic process. The system is composed by a heating element and sensing electrodes. They are both integrated in membrane in order to have a localized heating and sensing spot onto which the sensitive thin film is deposited. The microhotplates can operate with low consumption and can heat up to 500 °C with a good stability. This system has been already published in [1]. The use of lift-of process to restrict the deposition of the thin film onto central electrodes can lead to the dissolution and/or contamination of the sensitive layer. That's why the photolithographic method was avoided and a stencil mask process was used (Figure 1).



Figure 1: a) top-view of the membrane; b) mounted micro-sensor.

^[1] L. Presmanes, Y. Thimont, I. El Younsi, A. Chapelle, F. Blanc, C. Talhi, C. Bonningue, A. Barnabé, Ph. Menini, and Ph. Tailhades, "Integration of P-CuO Thin Sputtered Layers onto Microsensor Platforms for Gas Sensing", Sensors, vol. 17, #1409, June 2017.

The deposition conditions are shown in the Table I.

Target material	ZnO:Ga
Power (W)	(4 %at)
Magnetron	30
Argon pressure P (Pa)	Yes
Target to substrate distance	2
d (cm)	7

Table I: Deposition parameters of ZnO:Ga thin film by RF-sputtering.

The measurement protocol used in the test bench is a cycle of heating and cooling steps from 5 mW to 35 mW with a step of 5 mW for 5 min which correspond approximately to 50 °C to 350 °C. The tests were performed with 50% relative humidity. Alternation of air and air with 500 ppb of NO2 has been applied. In presence of air, the resistance is very low, close to 300 Ω , due the high conductivity of ZnO:Ga. When 500 ppb of NO₂ are injected, the resistance increases strongly up to 7 k Ω at 50 °C. The ratio R/R0 (where R is the resistance under NO₂ and R0 the resistance under air) has been calculated using the last points at each temperature step (Figure 2).



Figure 2: Response of ZnO:Ga vs temperature step (in cycled temperature mode).

Unlike the results we obtained in isothermal mode, the response in cycled temperature mode is much higher close to room temperature. Promising results with a response up to 18 for 500 ppb of NO₂ at 50 °C (R/R0 ~ 36 /ppm) have been highlighted.

3. Acknowledgement

This work has received funding from the Program Interreg-Sudoe of the European Union under grant agreement SOE2/P1/E0569 (NanoSen-AQM). This work was also partly supported by the French RENATECH network through technology developments in the CNRS-LAAS cleanroom